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VERSION WITH MARKINGS TO SHOW CHANGES MADE

TITLE:

Specification at page 1, line 1:

MULTILAYER CERAMIC SUBSTRATE AND METHOD FOR FABRICATING THE SAMEMETHOD FOR FABRICATING A MULTILAYER CERAMIC SUBSTRATE

SPECIFICATION:

Specification at page 1, line 5:

CROSS-RELATED APPLICATIONS

This application is a Divisional application of U.S. Patent Application Serial No. 09/173,288, filed October 14, 1998.

CLAIMS:

- 3. (As Amended) The method for fabricating a multilayer ceramic substrate
 recited in claim 1, A method for fabricating a multilayer ceramic substrate
 comprising the steps of:
- (a) manufacturing an intaglio plate of flexible resin substance, on which a first groove corresponding to a first conductive pattern is formed and a second groove having a depth deeper than that of the first groove is formed at a place corresponding to a via of the first conductive pattern;
 - (b) filling the first and the second grooves with an electroconductive paste;
- (c) increasing conductivity of respective paths in said first and second
 grooves by deaerating and drying the paste;

(d) adding additional electroconductive paste to said first and second
grooves to replenish a decremented volume of said paste;
(e) gluing said intaglio plate onto a ceramic substrate by applying heat and
pressure;
(f) separating said intaglio plate from said ceramic substrate to have a
pattern of the electroconductive paste transferred onto the ceramic substrate, and
burning it so as to form said first conductive pattern on the ceramic substrate;
(g) forming an insulation layer on said first conductive pattern, wherein said
insulation layer is formed by a printing technology covering the whole area of said
first conductive pattern, and is dried, said via is exposed through abrasion or
grinding of the dried skin of said insulation layer before burning and said insulation
layer is burned after the exposure of said via;
(h) forming a second conductive pattern on said insulation layer.

Claims 1, 2, and 4-21 have been cancelled.